Surface treatments for e-cloud mitigation

M.Taborelli

SPS-U team (G.Arduini, F.Caspers, K.Cornelis, E.Metral, G.Rumolo. E.Shaposhnikova, F.Zimmermann, E.Mahner, B.Henrist, S.Calatroni, P.Chiggiato, M.Taborelli, C.Yin-Vallgren), P.Costa Pinto, E.Benedetto

AT-VAC, TS-MME, AB/OP-RF-BI-ABP

Constraints for CLIC damping rings...and similar

The constraints in order to preserve beam quality are the following:

For e-cloud, low secondary electron yield (SEY): $\delta_{max} < 1.3$

For the pressure:

dynamic pressure below 10⁻¹⁰ mbar

NB: investigations in progress for the SPS to provide injection of nominal LHC luminosity and avoid electron cloud which would:

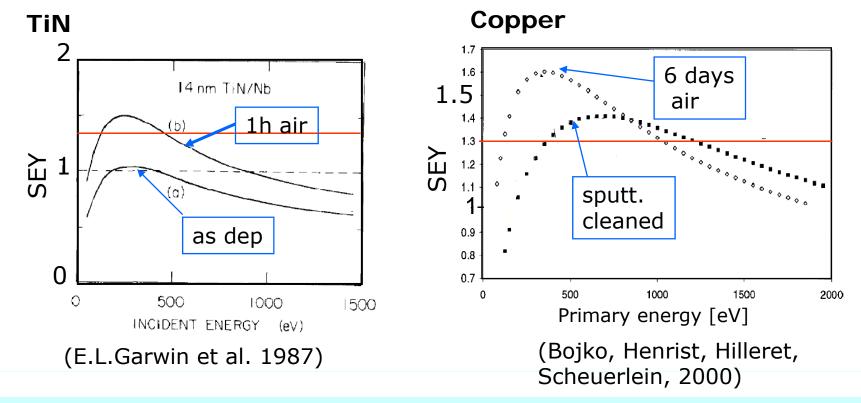
- increase the pressure by electron stimulated desorption
- provoke emittance growth
- provoke beam instability (head-tail, bunch-to-bunch coupling)
- interfere with the electrodes of beam monitors
- the threshold for electron cloud is also at $\delta max=1.3$ (25 ns spacing)

More on this in: <u>http://paf-spsu.web.cern.ch/paf-spsu/default.htm</u> by the SPSU team chaired by E.Shaposhnikova

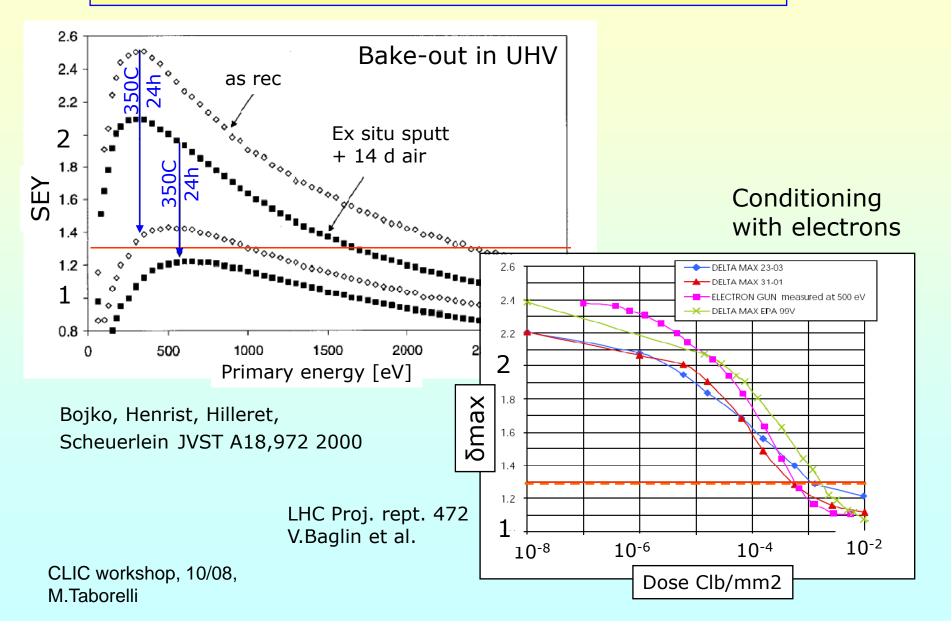
Surfaces with initially low SEY: effect of air exposure (without bakeout)

As deposited TiN has a $\delta max = 0.9-1.1$; clean copper has 1.3

Upon air exposure the TiN yield increases to $\delta max = 1.5$ -2.5 and the one of copper to $\delta max = 1.6$ -2.6



What can we gain with bakeout and conditioning? Ex: OFE-Copper



Two cases to be discussed:

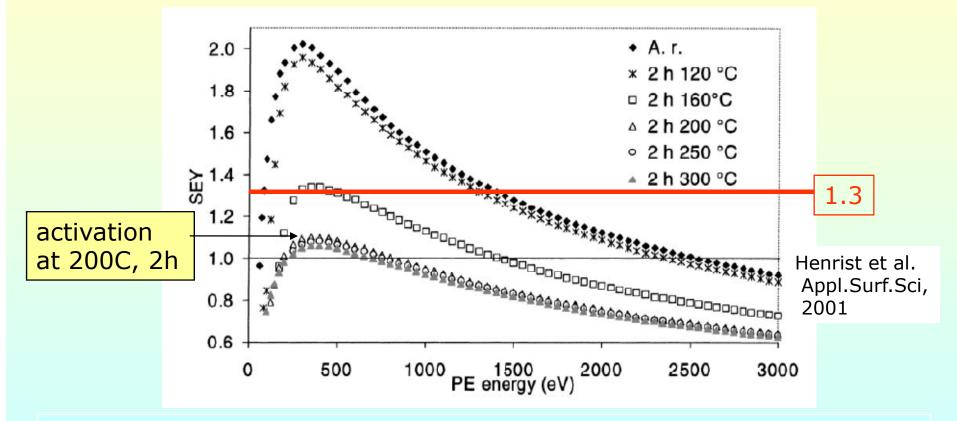
bakeable vacuum system NEG coatings non-bakeable vacuum system

-Low SEY smooth coatings -Macroscopically rough surfaces (not discussed here, can be used as substrate for low SEY coating)

SEY: Non Evaporable Getter (NEG) coatings

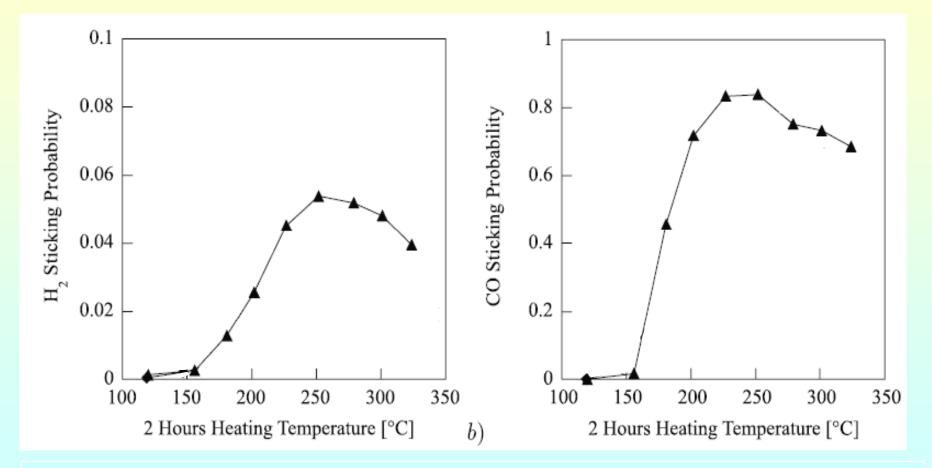
Bakeable system





-Thermal activation is necessary: 2h at 200C or 24h at 180C
-data for 7 re-activations after air-venting do not indicate e-activity in SPS (A.Rossi, CERN report 2005)
-Already coated by magnetron sputtering LHC long straight sections (6 km, more than 1000 chambers) to provide pumping

Pumping action of NEG: sticking probability of H_2 and CO upon thermal activation



-the pumping speed decreases as 1/n (n=number of venting/activation) and recovers by heating at higher T

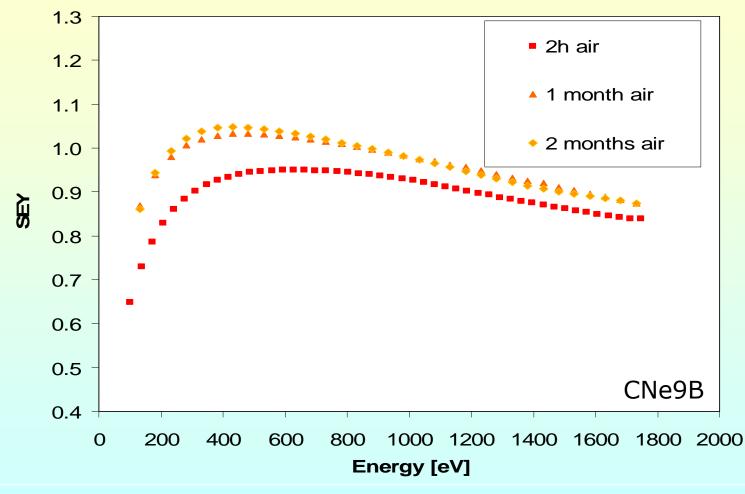
CLIC workshop, 10/08, M.Taborelli

Bakeable system

Non-Bakeable sys.

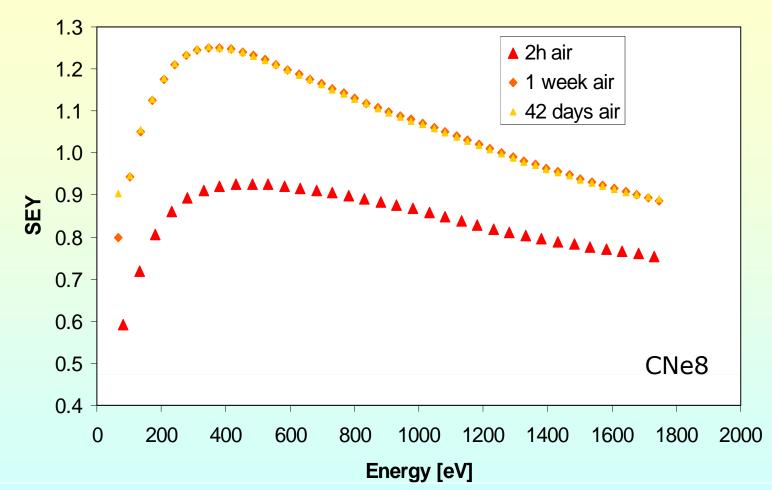
Amorphous carbon a-C coating: low SEY without bake

Non-Bakeable sys.



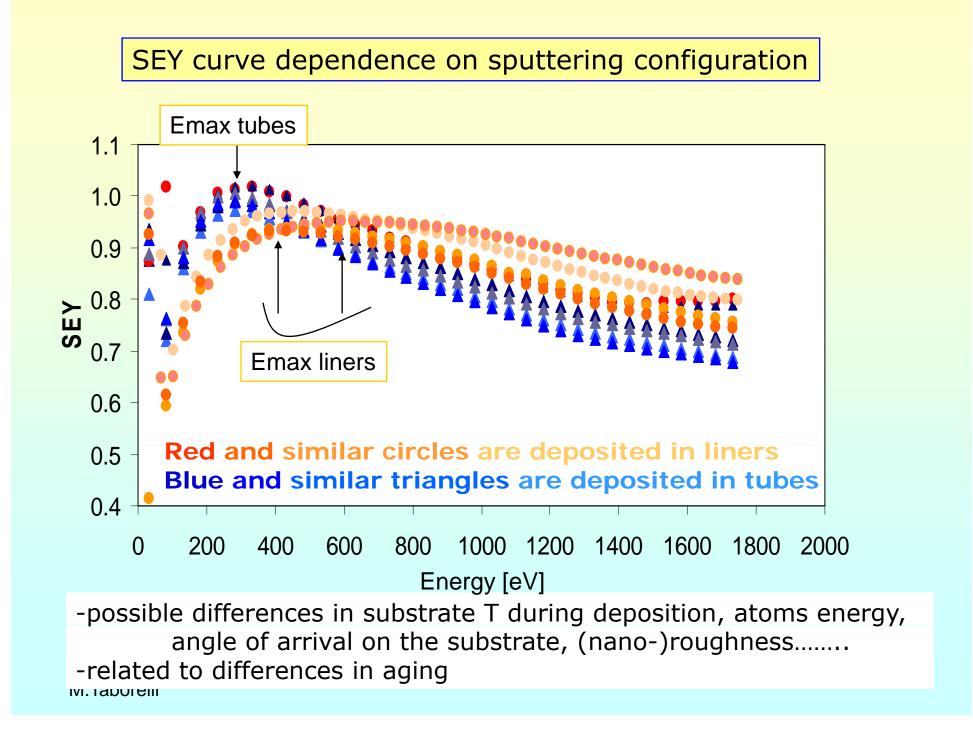
-a-C coating on copper deposited by magnetron sputtering (Ne) -thickness from 60-1300nm has been successfully tested

Amorphous carbon coating: "aging" in air



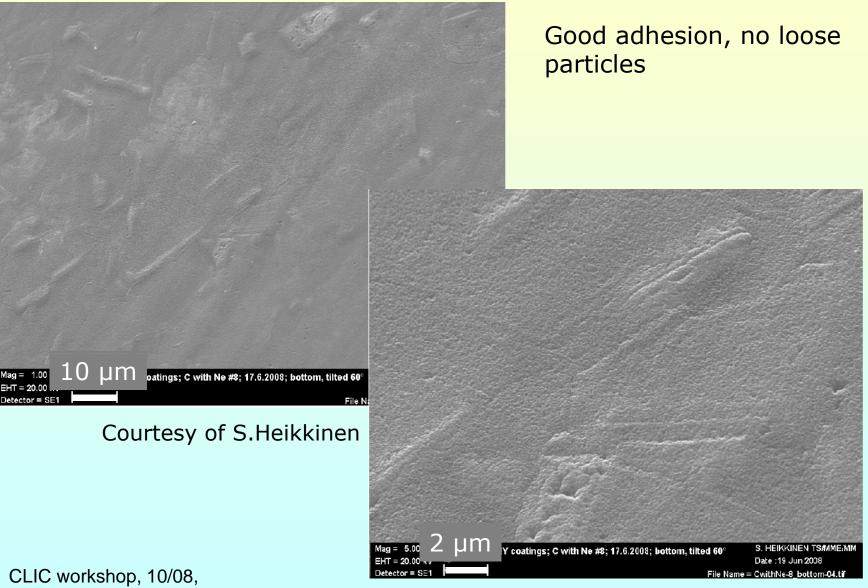
-The differences in "aging" in air are still under investigation
-It is important to specify a maximum air exposure time for the application!
-Can partly recover by bake 2h at 160C
M.Taborelli

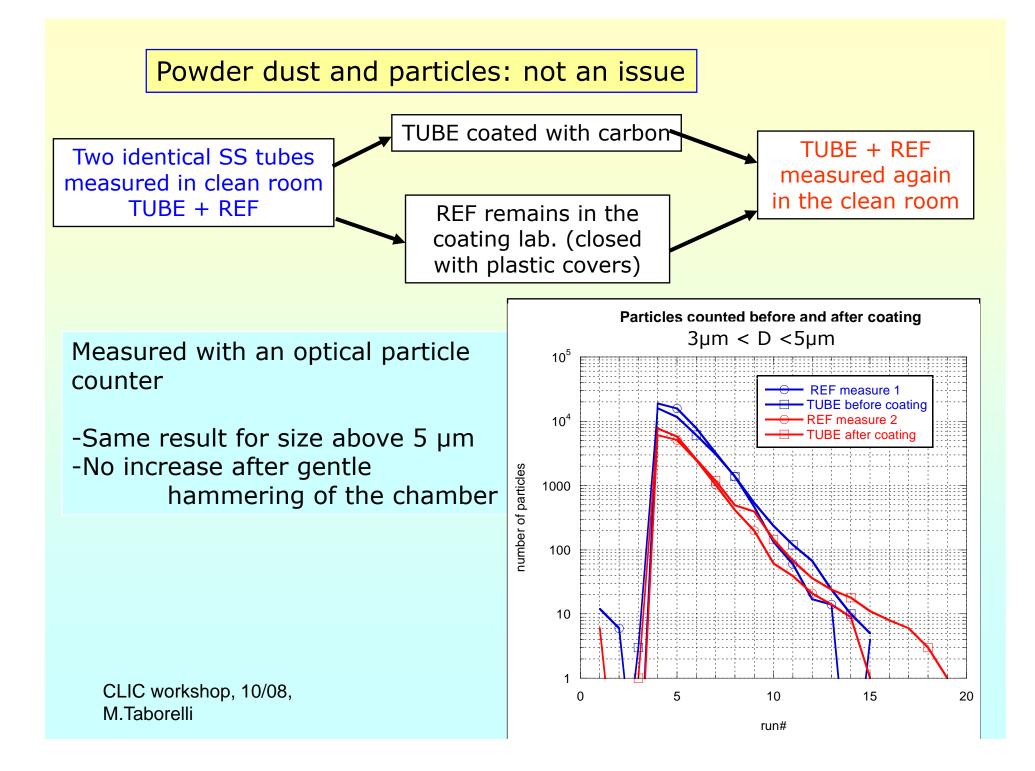
Non-Bakeable sys.



SEM images of CNe8



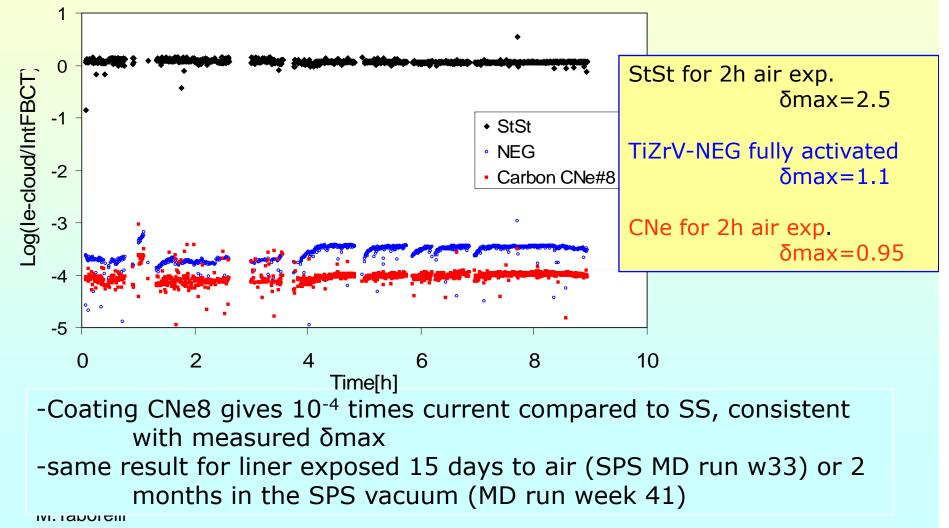




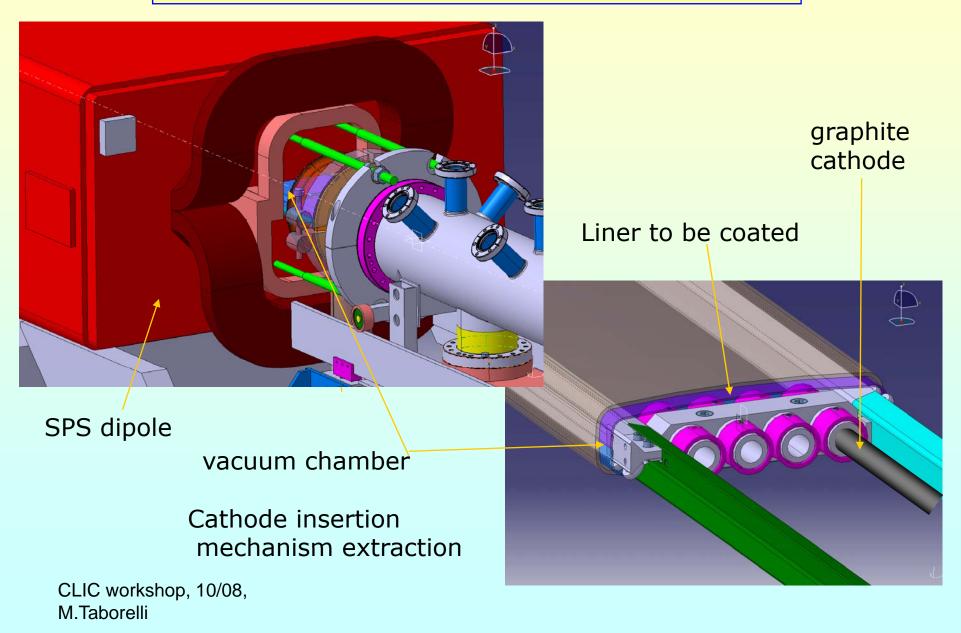
Strip detector in SPS, MD run w28

Set-up: a-C coated liner with strip detector in dipole magnet with 1.2KGauss field

Beam: 2-3 batches, 72 proton bunches, 25 ns spacing, 450 Gev/c



Preparation for SPS magnet prototype coating



Conclusions:

Bakeable system

-NEG is a valid solution for δmax<1.3 if the system can be baked at 180C or higher
 -the evolution after many venting cycles should be studied
 -NEG provides pumping
 -it is also conceivable to develop a coating with lower activation T

Non-bakeable system

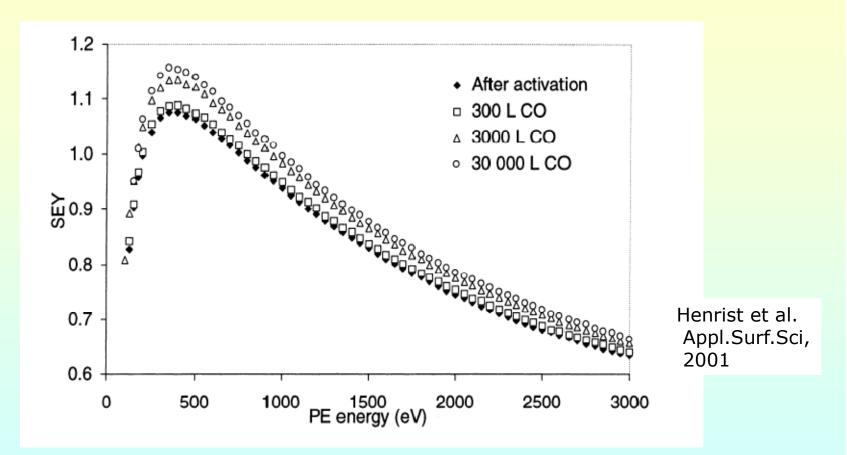
-a-C coating provides δmax <= 1 even after 2h air exposure
-aging of the coating in air is variable in the series of coatings produced so far, but δmax<1.3 for 1 week air exposure
-after 2 months exposure in the SPS vacuum or 15 days air exposure the coatings do not show increase of e-cloud activity
-pumpdown curves can be as good as for stainless steel, depending on the deposition parameters, ESD and PSD measurements in progress (lab and ESRF)
-no particles and peel-off
-to be characterized for impedance and photoyield

What can we gain with bakeout and conditioning? Ex: TiN 2 As received Baked 2 hrs Bake 150C 1.5 Baked 2+5=7hrs HILL As received, #2 Secondary Electron Yield 1 0.5 500 1000 1500 2000 2500 3000 0 2 12 Dys in vac 62 μC/mm² 1.5 Conditioning 583 µC/mm² <u>57</u>43 μC/mm² with electrons 1 0.5 1500 500 1000 2000 2500 3000 0 Energy (eV)

CLIC workshop, 10/08, M.Taborelli Le Pimpec et al. NIM A551, 187, (2005)

Bakeable system

Effect of surface saturation by CO:



-The δmax remains below 1.3 even after surface saturation with CO (300 L correspond to 7 days at 5x10⁻¹⁰ mbar)
 -Aging in air is less a concern, since re-activation for more than 20 times is possible

M.Taborelli

E-cloud data displayed as :

Int e-cloud current/Int FBCT =

current, integrated over all strips, integrated over a supercycle

FBCT signal, integrated over a supercycle

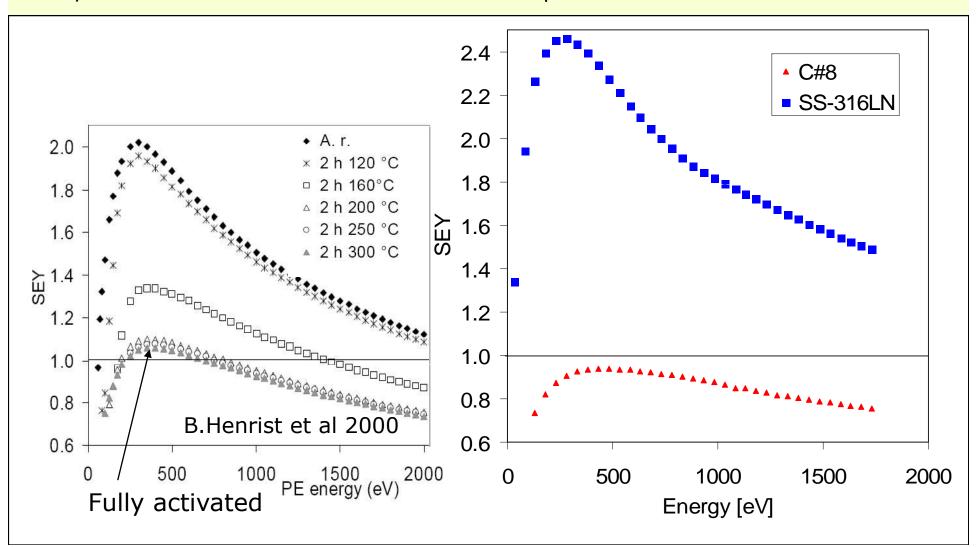
Dose calculated as:

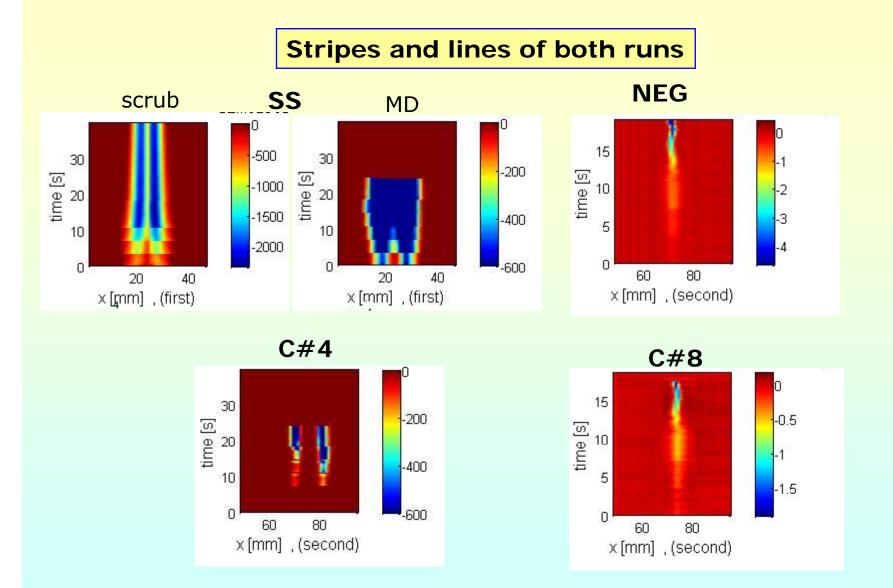
Dose [nC]= Current [nA] integrated over all strips, integrated over time and summed over the supercycles

NB: measured currents taken without consideration of transmission factor of the "grid" (7%)

SEY of the inserted materials

TiZrV-NEG, $\delta max=1.1$ fully activatedC#4, (scrub. run), $\delta max \sim 1.4$ for 2h air exp. (measurements at 500eV only)C#8,(MD) $\delta max=0.95$ for 2h air exp.SS, $\delta max=2.5$ for 2h air exp.





The single stripe could be just due to ionization of residual gas; the order of magnitude is close CLIC workshop, 10/08, M.Taborelli

Perspective and problems:

- -- Characterize and reproduce the C#8 type coating
- -- SEY increases upon air exposure; the kinetic of the effect is presently investigated with measurements in the lab to define a typical "allowed" exposure
- -- Other remedies: possible combination of carbon with rough substrate

